


EE C245 - ME C218 Introduction to MEMS Design Fall 2010

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Lecture Module 2: Benefits of Scaling


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Lecture Outline

- Reading: Senturia, Chapter 1
- Lecture Topics:
 - ↳ Benefits of Miniaturization
 - ↳ Examples
 - GHz micromechanical resonators
 - Chip-scale atomic clock
 - Micro gas chromatograph

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 **Benefits of Size Reduction: MEMS**


- Benefits of size reduction clear for IC's in elect. domain
↳ size reduction ⇒ speed, low power, complexity, economy
- MEMS: enables a similar concept, but ...
MEMS extends the benefits of size reduction beyond the electrical domain



Performance enhancements for application domains beyond those satisfied by electronics in the same general categories

- Speed → Frequency ↑ , Thermal Time Const. ↓
- Power Consumption → Actuation Energy ↓ , Heating Power ↓
- Complexity → Integration Density ↑ , Functionality ↑
- Economy → Batch Fab. Pot. ↑ (esp. for packaging)
- Robustness → g-Force Resilience ↑

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 **Vibrating RF MEMS**

Vibrating RF MEMS

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Basic Concept: Scaling Guitar Strings

Guitar String

Vib. Amplitude vs Freq. (110 Hz)

Vibrating "A" String (110 Hz)

Freq. Equation:

$$f_o = \frac{1}{2\pi} \sqrt{\frac{k_r}{m_r}}$$

Labels: Stiffness (k_r), Mass (m_r), Freq. (f_o)

μ Mechanical Resonator

Metallized Electrode, Anchor, Polycrystalline Clamped-Clamped Beam

[Bannon 1996]

Performance:

- $L_r = 40.8 \mu\text{m}$
- $m_r \sim 10^{-13} \text{ kg}$
- $W_r = 8 \mu\text{m}, h_r = 2 \mu\text{m}$
- $d = 1000 \text{ \AA}, V_p = 5 \text{ V}$
- Press. = 70 mTorr

Graph parameters: $f_o = 8.5 \text{ MHz}$, $Q_{vac} = 8,000$, $Q_{air} \sim 50$

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Frequency of a Stretched Wire

Scaling of Guitar Strings!

guitar string \equiv transversely vibrating stretched wire

B.C. Simple Support $z(x=0)=0$, $z(x=L)=0$

\Rightarrow Equation for Resonance Freq. (fundamental mode)

$$f_1 = \frac{1}{2L} \sqrt{\frac{S}{\rho}}$$

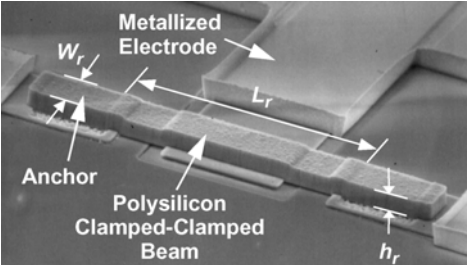
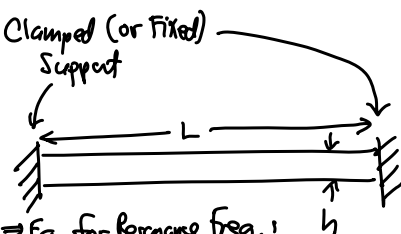
Labels: S = tension (force per unit area), ρ = mass per unit length

This is a good approx. for a guitar string \rightarrow but for the MEMS device, thickness might approach length \rightarrow better described as a beam (length much larger than thickness)

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UC Berkeley **Frequency of a Clamped-Clamped Beam**

Clamped-Clamped Beam

⇒ Eq. for Resonance Freq. 1

$$f_0 = \frac{1}{2\pi} \sqrt{\frac{k}{m}} = 1.03 \sqrt{\frac{E}{\rho}} \frac{h}{L^2} \quad (1)$$

where $E \hat{=}$ Young's modulus [GPa]
 $\rho \hat{=}$ density [kg/m³]
 $h \hat{=}$ thickness [m]
 $L \hat{=}$ length [m]

Example. $L = 40 \mu\text{m}$, $h = 2 \mu\text{m}$
 polysi $\rightarrow E = 150 \text{ GPa}$, $\rho = 2300 \text{ kg/m}^3$

$$\therefore f_0 = (1.03) \sqrt{\frac{1506}{2300}} \frac{2\mu}{(40\mu)^2} \rightarrow \boxed{f_0 = 10.4 \text{ MHz}}$$

acoustic velocity = 8076 m/s As $L \downarrow \rightarrow f_0 \uparrow$!

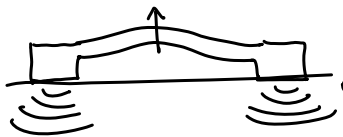
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UC Berkeley **Frequency of a Clamped-Clamped Beam**

Example. $L = 4 \mu\text{m} \rightarrow f_0 = (1.03) (8076) \frac{2\mu}{(4\mu)^2} \rightarrow \boxed{f_0 = 1.04 \text{ GHz}}$

Remarks.

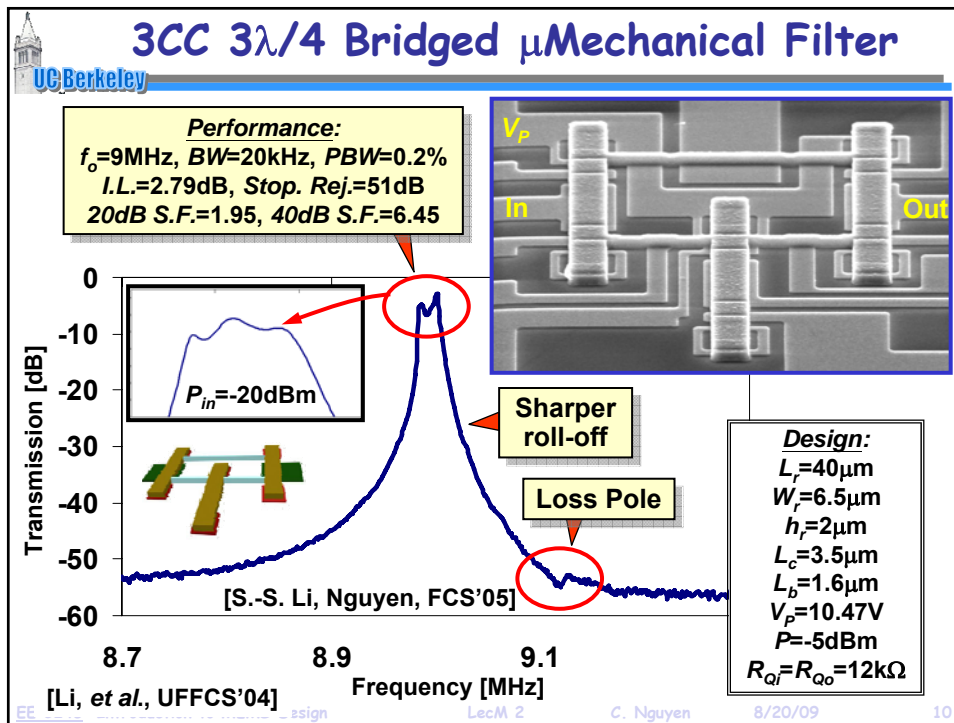
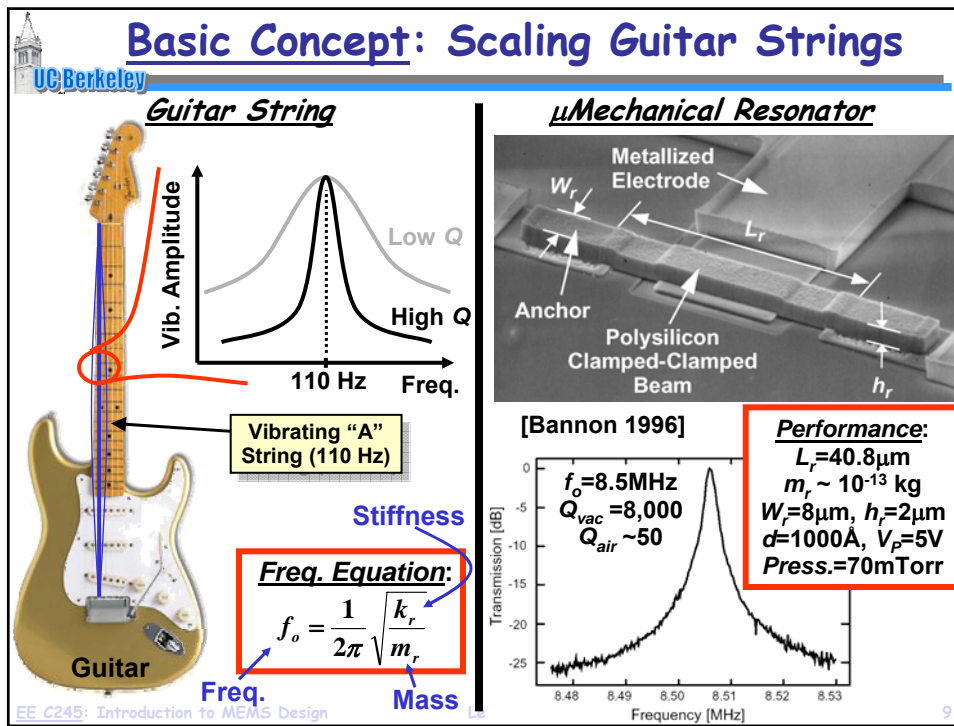
- ① Eq. (1) not accurate when $L \approx h$. (See HW#1)
- ② When $L \approx h$ (a when it isn't more than $10 \times h$), anchor losses become an issue



Smaller & Faster!

- ③ Solution: non-dimensional? ✓
- ④ Better Solution: other geometries ✓

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1.51-GHz, $Q=11,555$ Nanocrystalline Diamond Disk μ Mechanical Resonator

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- Impedance-mismatched stem for reduced anchor dissipation
- Operated in the 2nd radial-contour mode
- $Q \sim 11,555$ (vacuum); $Q \sim 10,100$ (air)
- Below: 20 μm diameter disk

Design/Performance:
 $R=10\mu\text{m}$, $t=2.2\mu\text{m}$, $d=800\text{\AA}$, $V_p=7\text{V}$
 $f_o=1.51\text{ GHz}$ (2nd mode), $Q=11,555$

Mixed Amplitude [dB]

Frequency [MHz]

$f_o = 1.51\text{ GHz}$
 $Q = 11,555$ (vac)
 $Q = 10,100$ (air)

$Q = 10,100$ (air)

EE C245: Introduction to MEMS Design LecM 2 [Wang, Butler, Nguyen MEMS'04]

163-MHz Differential Disk-Array Filter

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Com. Array Couplers

Filter Coupler

Port1 v_{i+}

Port3 v_{o+}

Port2 v_{i-}

Port4 v_{o-}

Diff. Array Couplers

V_p

$\lambda/2$, $\lambda/4$, λ

[Li, Nguyen Trans'07]

Linear MEMS in Wireless Comms

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High Q and good linearity of micromechanical resonators

Filters for front-end frequency selection

Micromechanical Bandpass Filter

Antenna Diplexer RF BPF LNA Mixer I LPF AGC A/D

From TX 0° 90° RXRF LO RF PLL Xstal Osc

Mixer Q LPF AGC A/D

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Miniaturization of RF Front Ends

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RF Power Amplifier

Diplexer

897.5±17.5MHz RF SAW Filter

925-960MHz RF SAW Filter

Dual-Band Zero-IF Transistor Chip

1805-1880MHz RF SAW Filter

3420-3840MHz VCO

26-MHz Xstal Oscillator

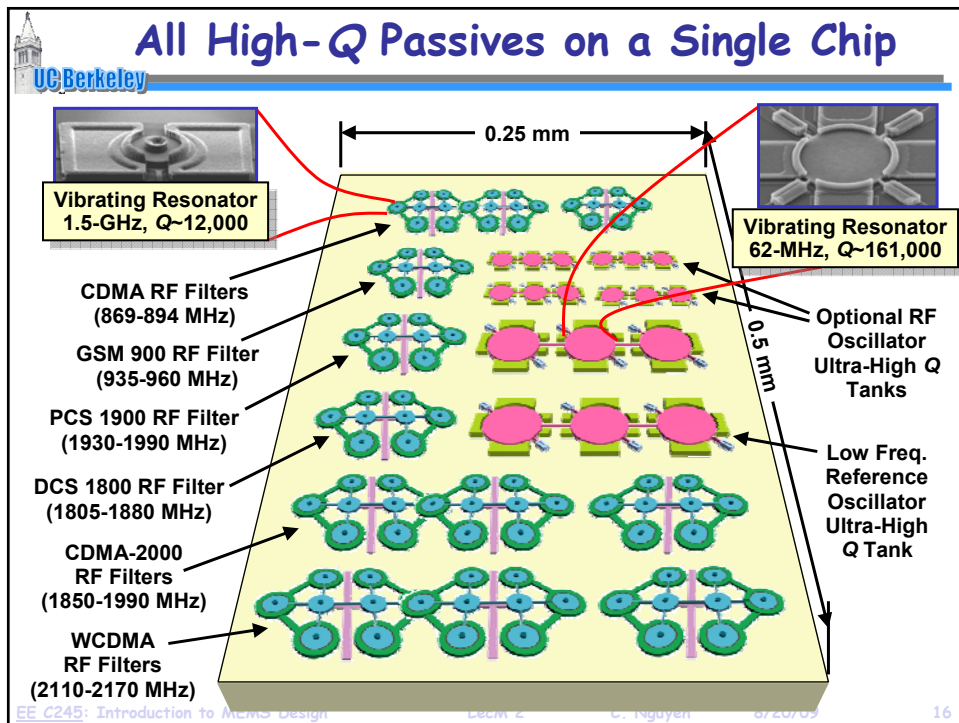
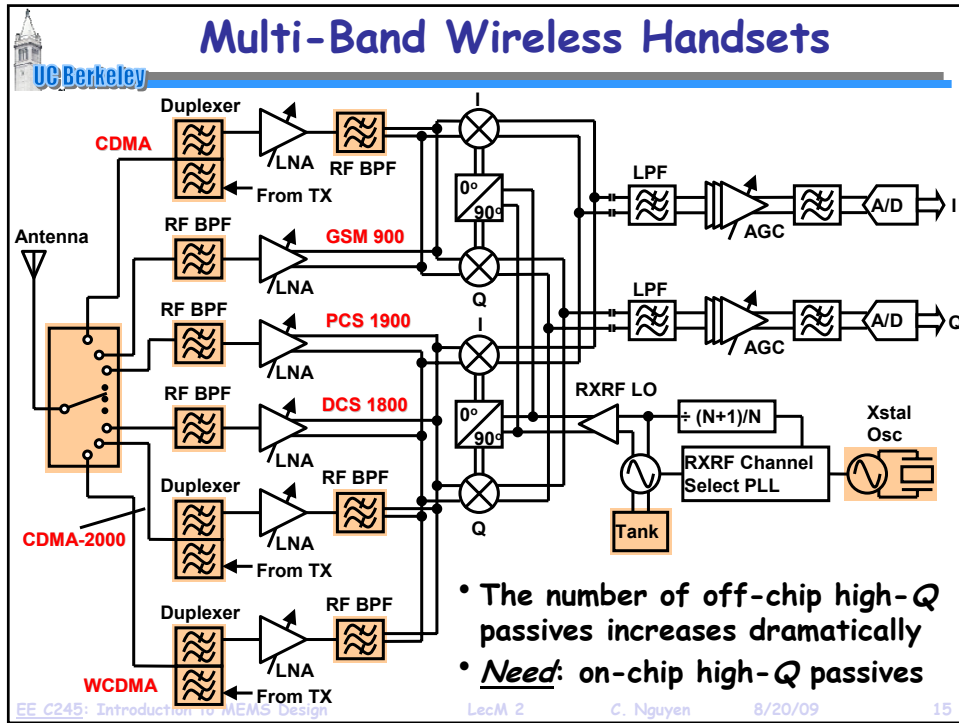
Problem: high-Q passives pose a bottleneck against miniaturization

Antenna Diplexer RF BPF LNA Mixer I LPF AGC A/D

From TX 0° 90° RXRF LO RF PLL Xstal Osc

Mixer Q LPF AGC A/D

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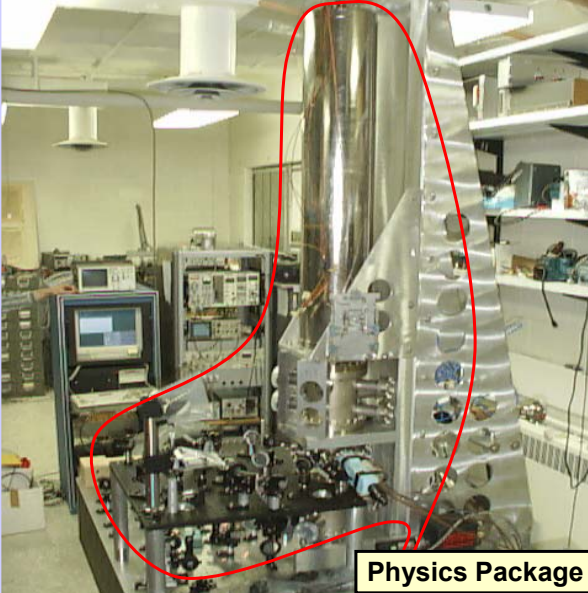
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Chip-Scale Atomic Clocks (CSAC)

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NIST F1 Fountain Atomic Clock



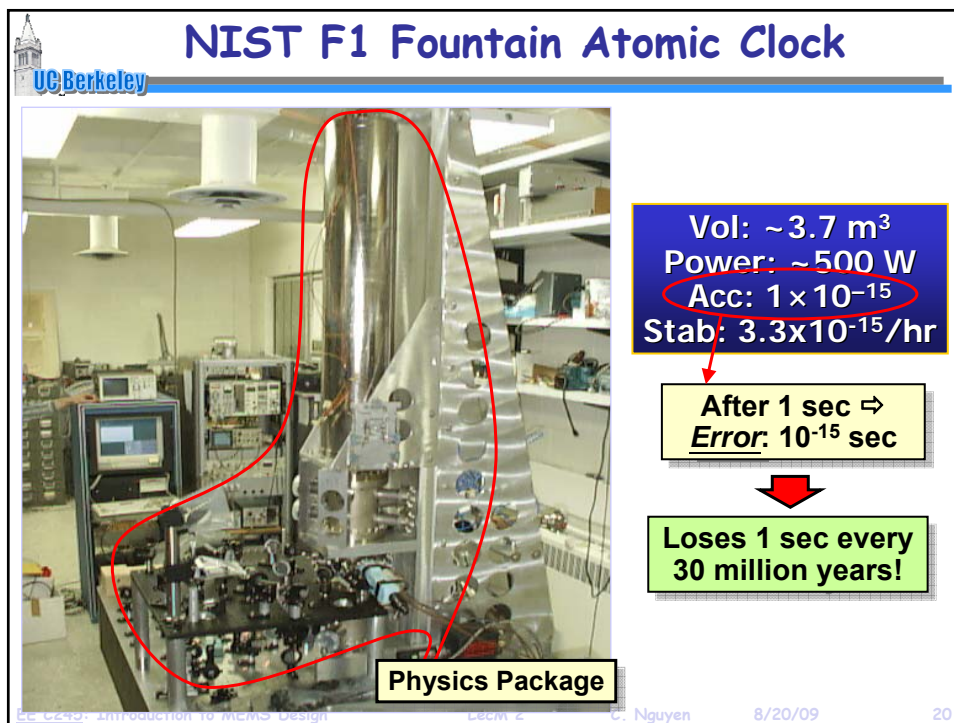
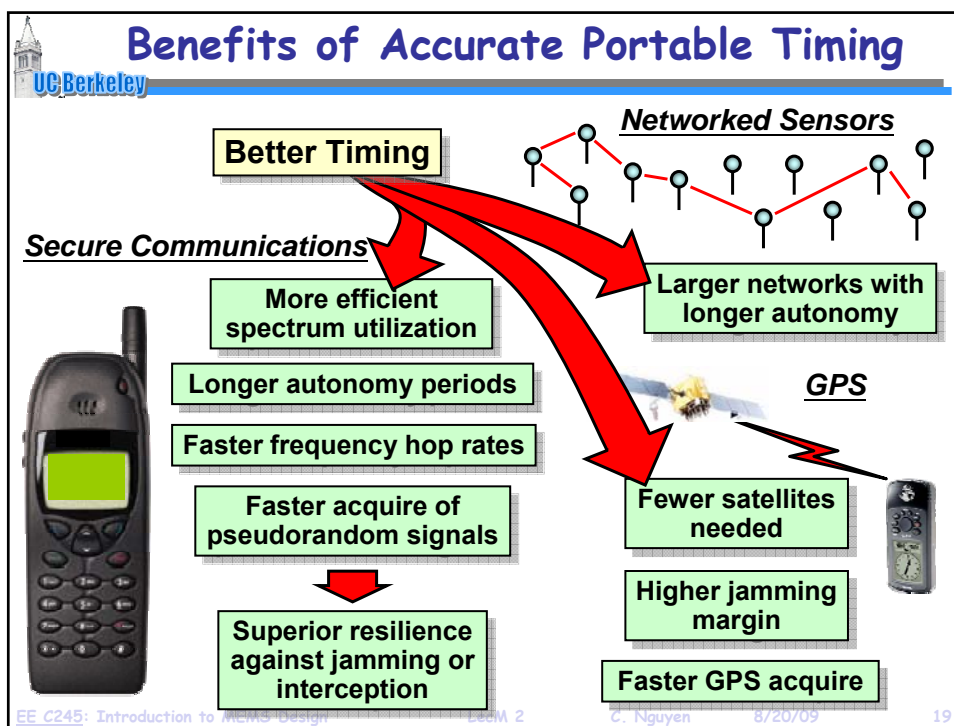
Vol: $\sim 3.7 \text{ m}^3$
Power: $\sim 500 \text{ W}$
Acc: 1×10^{-15}
Stab: $3.3 \times 10^{-15} / \text{hr}$

After 1 sec \Rightarrow
Error: 10^{-15} sec

Loses 1 sec every
30 million years!

Physics Package

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1st Chip-Scale Atomic Physics Package

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NIST's Chip-Scale Atomic Physics Package

Photodiode
Cell
Optics
Laser

1.5 mm
4.2 mm
1.5 mm

ND
Quartz
Si
ND
Glass
Alumina
VCSEL
Lens

Total Volume: 9.5 mm³ Stability: 2.4 x 10⁻¹⁰ @ 1s
 Cell Interior Vol: 0.6 mm³ Power Cons: 75 mW

Tiny Physics Package Performance

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NIST's Chip-Scale Atomic Physics Package

Dime

- **Experimental Conditions:**
 Cs D2 Excitation
 External (large) Magnetic Shielding
 External Electronics & LO
 Cell Temperature: ~80 °C
 Cell Heater Power: 69 mW
 Laser Current/Voltage: 2mA / 2V
 RF Laser Mod Power: 70μW

Open Loop Resonance:

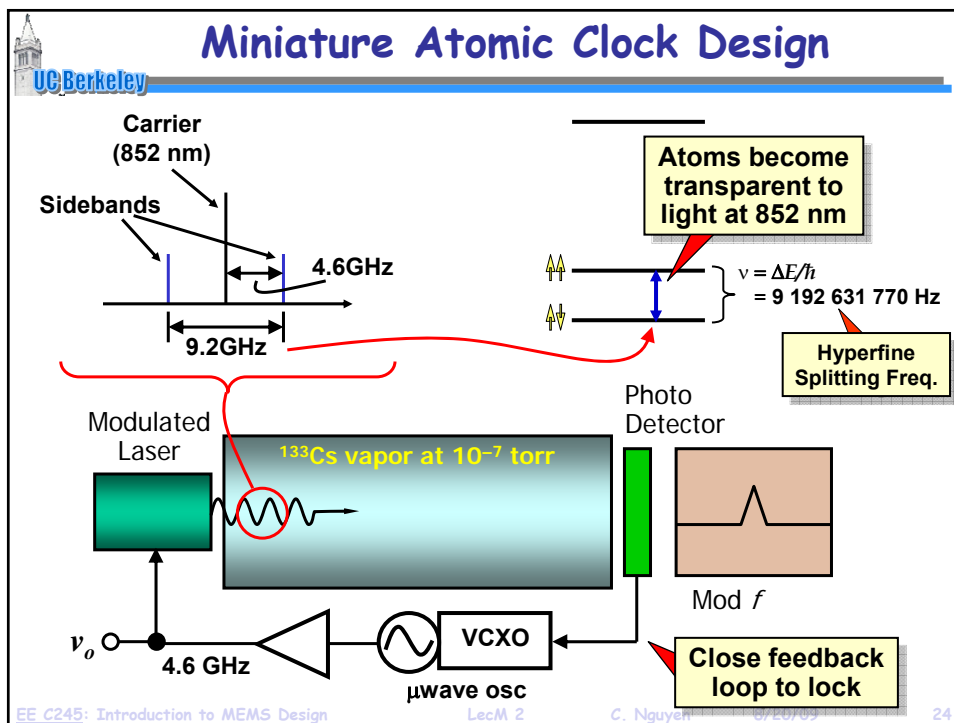
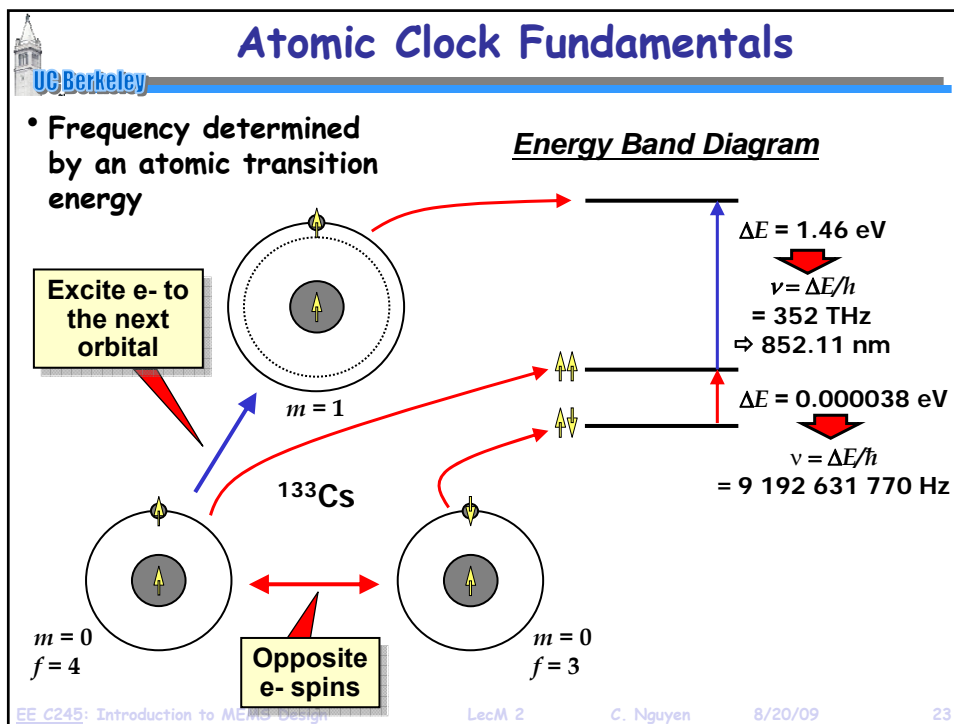
Q = 1.3x10⁶
 Contrast: 0.91%
 Sufficient to meet CSAC program goals

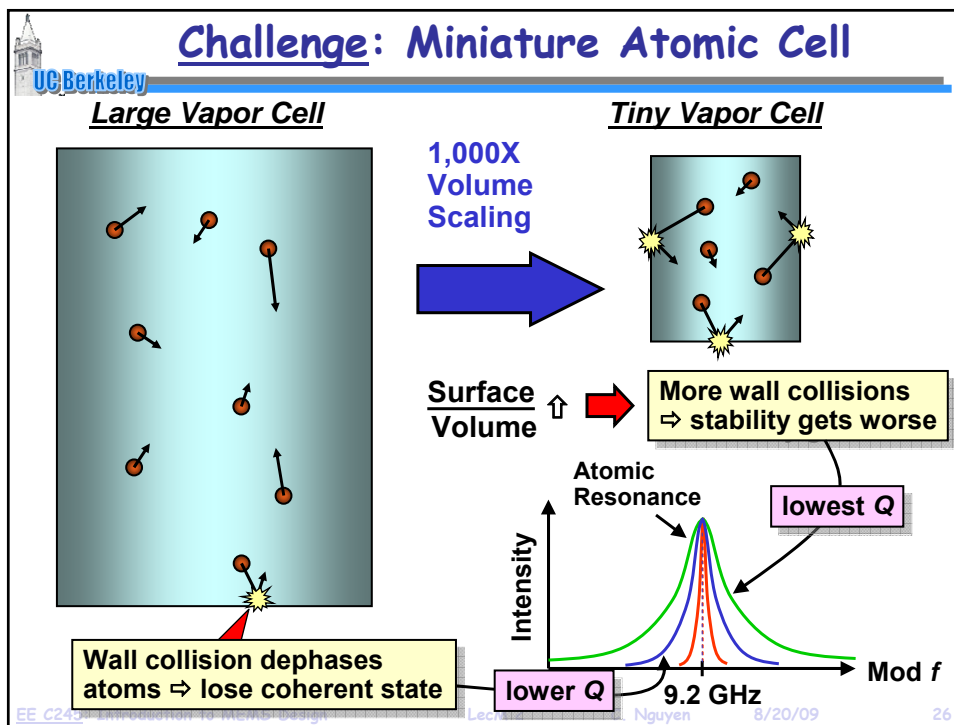
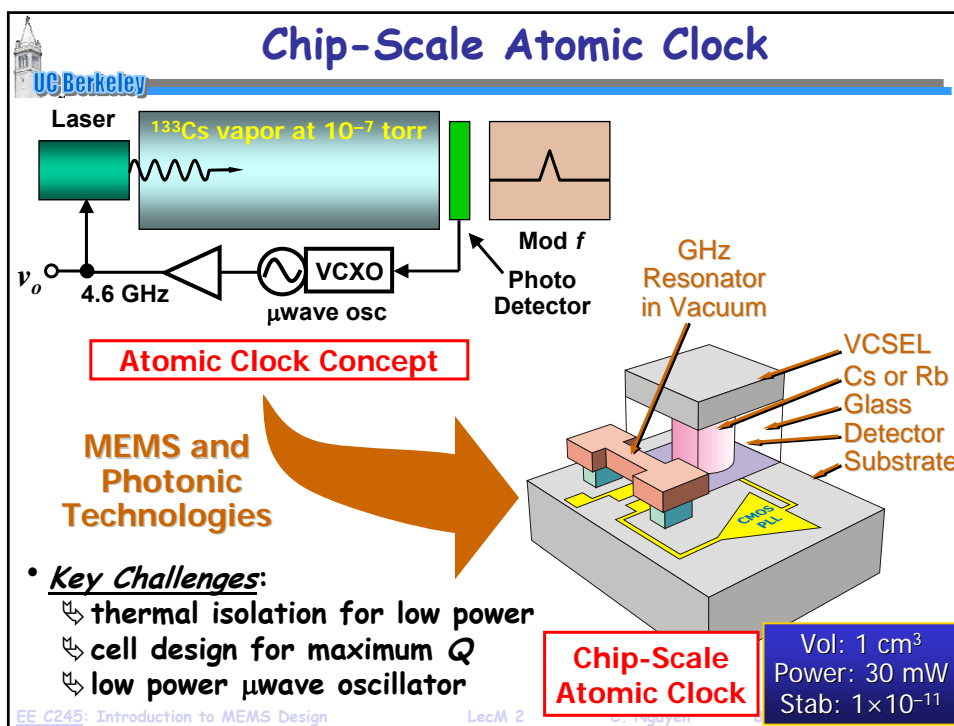
PD Signal [V]
 Frequency Detuning, Δ [kHz] from 9,192,631,770 Hz

Stability Measurement:

Allan Deviation, σ_y
 Integration Time, τ [s]

Cs (D₂)
 Rb (D₁)
 Drift Issue
 CSAC Goal
 1 hour
 1 day





Challenge: Miniature Atomic Cell

Large Vapor Cell

1,000X Volume Scaling

➔

Tiny Vapor Cell

Soln: Add a buffer gas → Lower the mean free path of the atomic vapor

Intensity vs Mod f
 9.2 GHz
 Atomic Resonance
 Return to higher Q

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Chip-Scale Atomic Clock

Atomic Clock Concept

MEMS and Photonic Technologies

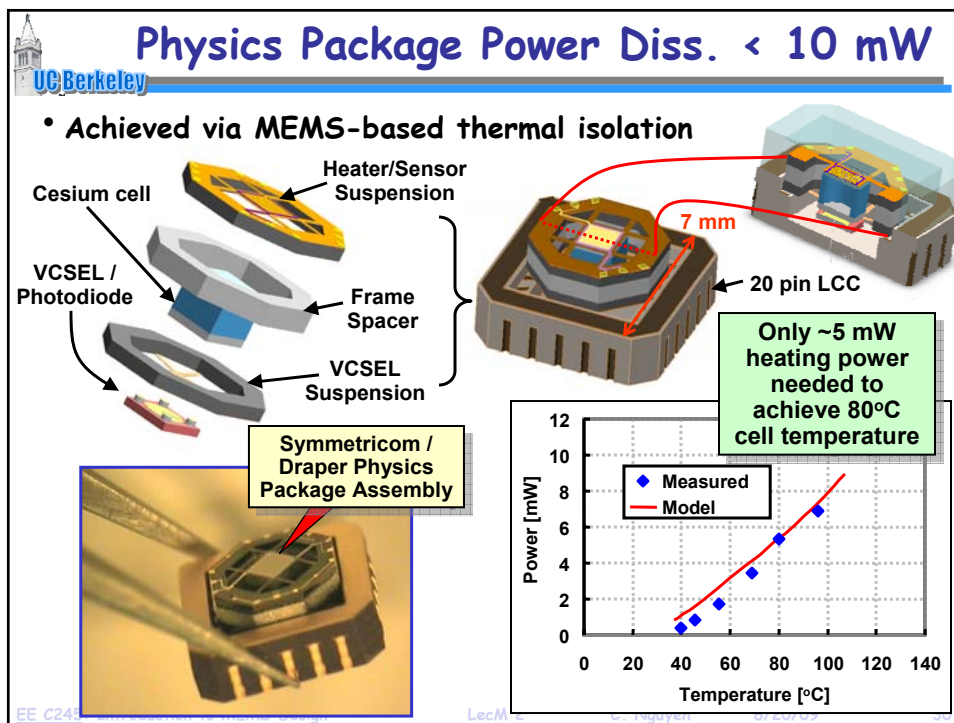
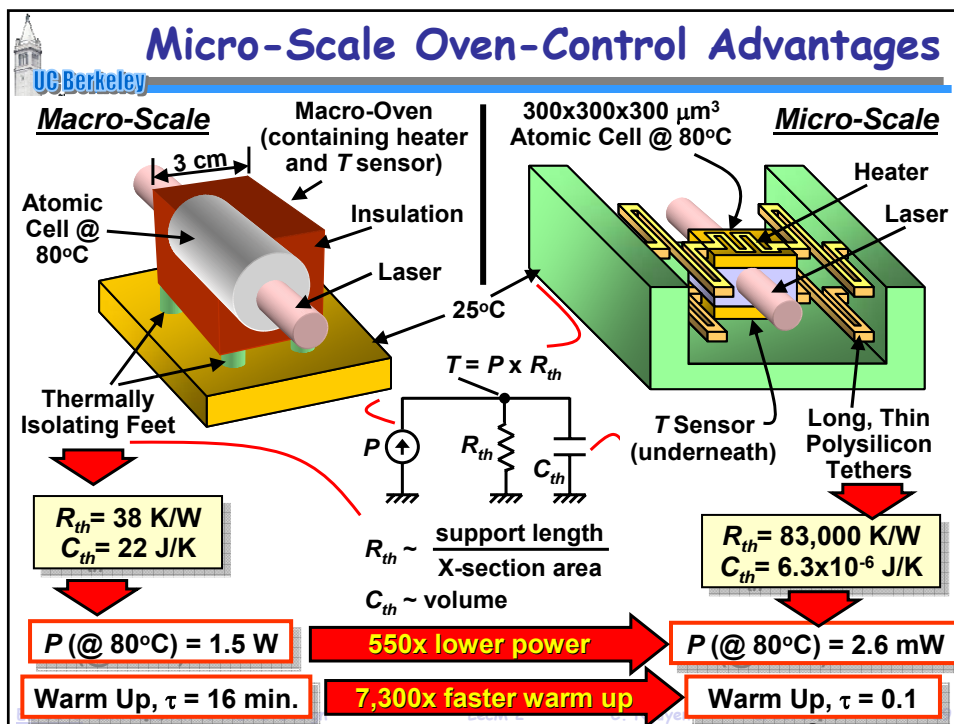
Key Challenges:

- ↳ thermal isolation for low power
- ↳ cell design for maximum Q
- ↳ low power μ wave oscillator

Chip-Scale Atomic Clock

Vol: 1 cm^3
 Power: 30 mW
 Stab: 1×10^{-11}

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Thermal Circuit Modeling

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Macro-Scale

Atomic Cell @ 80°C
 Macro-Oven (containing heater and T sensor)
 Insulation
 Laser
 Thermally Isolating Feet
 25°C

⇒ All physical pieces possess a thermal capacity & a thermal resistance

$l \triangleq \text{length}$
 $A \triangleq \text{cross-sectional area}$

⇒ **Thermal Capacitance:**

$$C_{th} = \rho V C_p$$

ρ ← specific heat
 V ← volume
 ρ ← density

⇒ **Thermal Resistance:**

$$R_{th} = \frac{l}{kA}$$

l ← length
 k ← thermal conductivity
 A ← cross-sectional area

⇒ **Thermal Ckt:**

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Thermal Circuit Modeling

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h = 3 cm
 W
 L = 3 cm
 Atomic Cell @ 80°C
 Insulation
 Laser
 Thermally Isolating Feet
 25°C
 Glass
 R_{cell} = 1 cm

Example: Power to maintain cell T = 80°C
 ⇒ for materials identified in the figure: (all glass)

$C_{p, \text{glass}} = 0.5 \text{ J/(g}\cdot\text{K)}$
 $\rho_{\text{glass}} = 2500 \text{ kg/m}^3$

$k_{\text{glass}} = 1.05 \frac{\text{W}}{\text{m}\cdot\text{K}}$

Eqv. Ckt:

⇒ ignore the small R_{th} of the cell
 ⇒ ignore the small C_{th} of the feet

Reduce

$T = PR_{th}$ in steady-state

$R_{th} = \frac{R_{th, \text{feet}}}{4}$

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Thermal Circuit Modeling

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⇒ When power is switched on

and for the cell:

$$C_{th,cell} = \rho_{glass} V_{cell} C_{p,glass}$$

$$= (2500 \frac{kg}{m^3}) (1000 \frac{m^3}{kg}) (\frac{1}{100^3} \frac{m^3}{cm^3}) \times (20.7 \frac{J}{g \cdot K}) (0.5 \frac{g}{kg})$$

⇒ $C_{th,cell} = 25.9 \text{ J/K}$

Find $R_{th,foot}$:

⇒ foot dimensions:

$R_{foot} = 2 \text{ mm}$ $A_{foot} = \pi R_{foot}^2$
 $L_{foot} = 2 \text{ mm}$

Find $C_{th,cell}$:

⇒ Find volume of the cell

$$V_{cell} = hWL - \pi R_{cell}^2 \cdot L$$

$$= (3 \text{ cm})(3 \text{ cm})(3 \text{ cm}) - \pi (1 \text{ cm})^2 (2 \text{ cm})$$

$$= 20.7 \text{ cm}^3$$

(again, ignore the R_{th} of the cell)

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Thermal Circuit Modeling

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$R_{th,foot} = \frac{l_{foot}}{k_{glass} \cdot A_{foot}} = \frac{2 \text{ mm}}{(1.05 \frac{W}{m \cdot K}) \pi (2 \text{ mm})^2}$

⇒ $R_{th,foot} = 151.6 \text{ K/W}$

Since there are 4 feet, the equivalent thermal ckt. becomes:

⇒ find the time constant:

$$\tau = \left(\frac{R_{th,foot}}{4} \right) \cdot C_{th} = 16.4 \text{ min}$$

Time req'd to warm up & stabilize will be 3x this!

∴ must wait ~45 min. before using this clock!

Now, let's see what happens when we shrink the size of the atomic cell to MEMS-like dimensions ...

⇒ find power req'd to maintain T_{∞} in steady state:

$$P = \frac{T_{\infty} - T_0}{(R_{th,foot}/4)} = \frac{(80 - 25)}{9.48} = 1.45 \text{ W}$$

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MEMS Thermal Circuit Modeling

300x300x300 µm³ } hollow w/
 Atomic Cell @ 80°C } 10µm-thick walls
 (glass)

Heater
 Laser
 T Sensor (underneath)
 Long, Thin Polysilicon Tethers

25°C

→ 500 µm-long, 10 µm-thick, 20 µm-wide

$V_{cell} = (300\mu)(300\mu)(300\mu) - (280\mu)(280\mu)(280\mu)$
 $= 5.048 \times 10^{-12} \text{ m}^3$

↳ of course, much smaller than macro

$$C_{th,cell} = \rho_{glass} V_{cell} C_{p,glass}$$

$$= (2500 \frac{\text{kg}}{\text{m}^3}) (5.048 \times 10^{-12} \text{ m}^3)$$

$$\times (500 \frac{\text{J}}{\text{kg}\cdot\text{K}})$$

$$\Rightarrow C_{th,cell} = \underline{6.31 \times 10^{-6} \frac{\text{J}}{\text{K}}}$$

↳ 4 million x smaller than macro!

$$R_{th,supp} = \frac{L_{supp}}{k_{psil} \cdot w_{supp} \cdot h_{supp}}$$

$$= \frac{500\mu}{(30 \frac{\text{W}}{\text{m}\cdot\text{K}})(20\mu)(10\mu)} = \underline{83,333 \text{ K/W}}$$

↳ 548x larger

and...

$$P = \frac{(80-25)}{83,333} = \underline{2.64 \text{ mW}}$$

↳ 548x smaller!

$$\tau = \underline{0.13 \text{ s}}$$

↳ 7300x faster! All due to scaling!

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Micro Gas Analyzers (MGA)

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Micro Gas Analyzers

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- Objective:** enable remote detection of chemical agents via tiny, ultra-low power, fast, chip-scale gas analyzers that greatly reduce the incidence of false positives
- Approach:** use micromachining technologies to implement separation-based analyzers (e.g., gas chromatographs, mass spectrometers) at the micro-scale to enhance gas selectivity

Conventional Sensor

Capacitor Plates Gas Sensitive Polymer

Species A Species B

$\Delta C \sim$ gas conc.

Separation Analyzer

Species A Species B

- Problem:** polymer has finite sensitivity to both A & B
- Result:** species A & B now separated \Rightarrow can identify and analyze individually

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Advantages of Miniaturization

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Portable Gas Chromatograph

19" Depth = 10"
13"

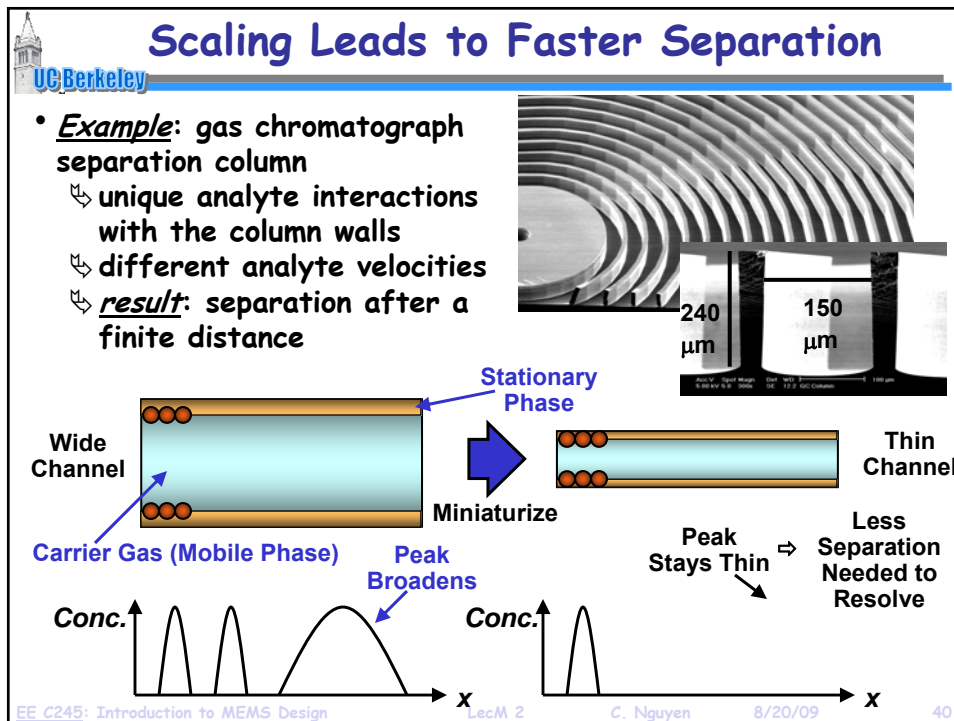
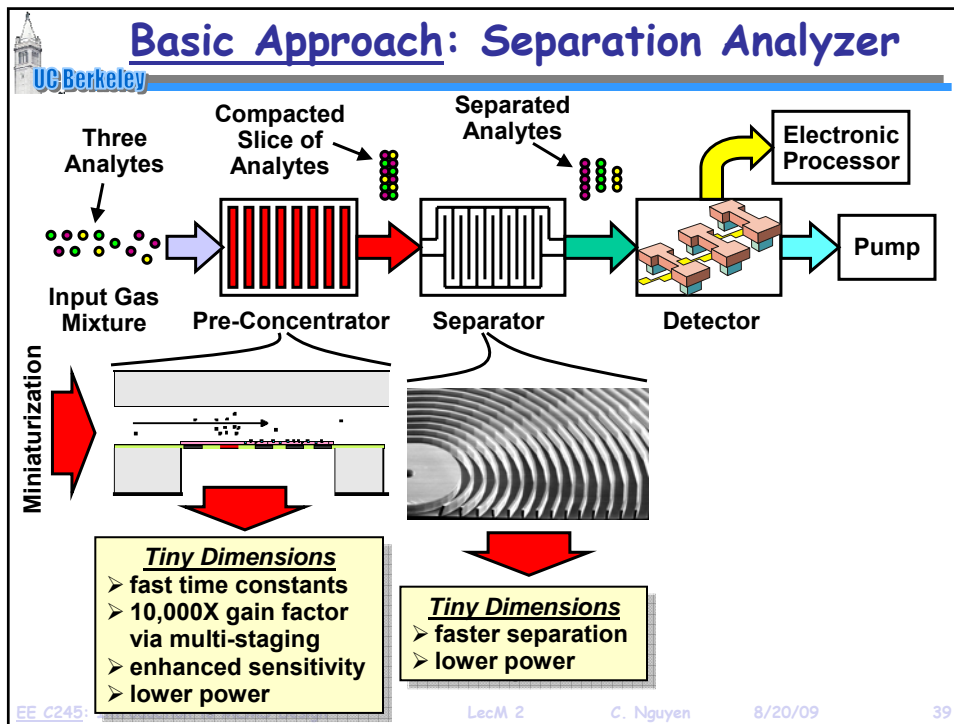
Chip-Scale Gas Chromatograph

Preconcentrator Detector Array
1-2 cm 5 mm
Separation Column Micropump

Reduction Factors

Size	40,500 cm ³	20,000X	Size	2 cm ³
Sensitivity	1 ppb	1,000X	Sensitivity	1 ppt
Analysis Time	15 min.	225X	Analysis Time	4 sec
Energy Per Analysis	10,000 J	10,000X	Energy Per Analysis	1 J

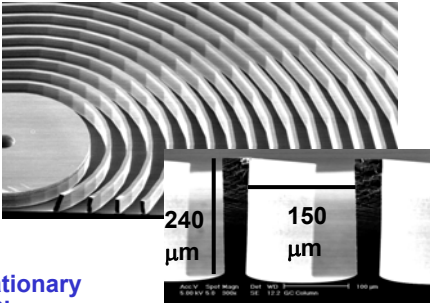
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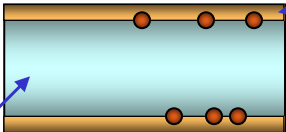
Scaling Leads to Faster Separation

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- Example:** gas chromatograph separation column
 - ↪ unique analyte interactions with the column walls
 - ↪ different analyte velocities
 - ↪ **result:** separation after a finite distance



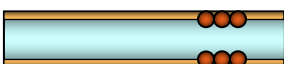
Wide Channel



Carrier Gas (Mobile Phase)

➔

Thin Channel



Miniaturize

Column Width ↓

➔

Surface-to-Volume Ratio ↑

➔

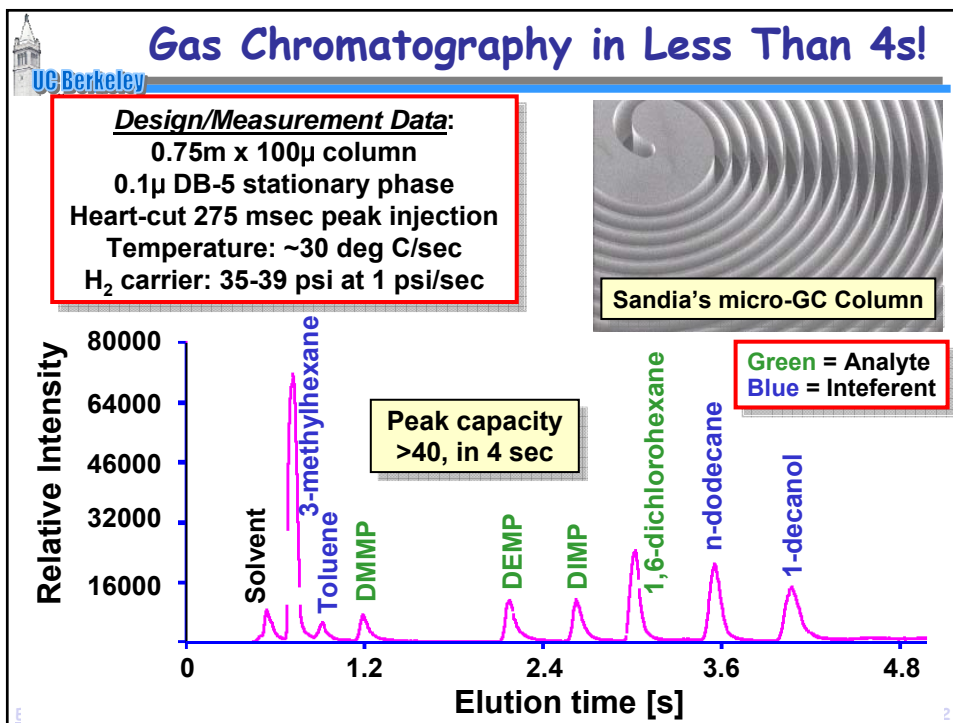
Peak Spreading ↓

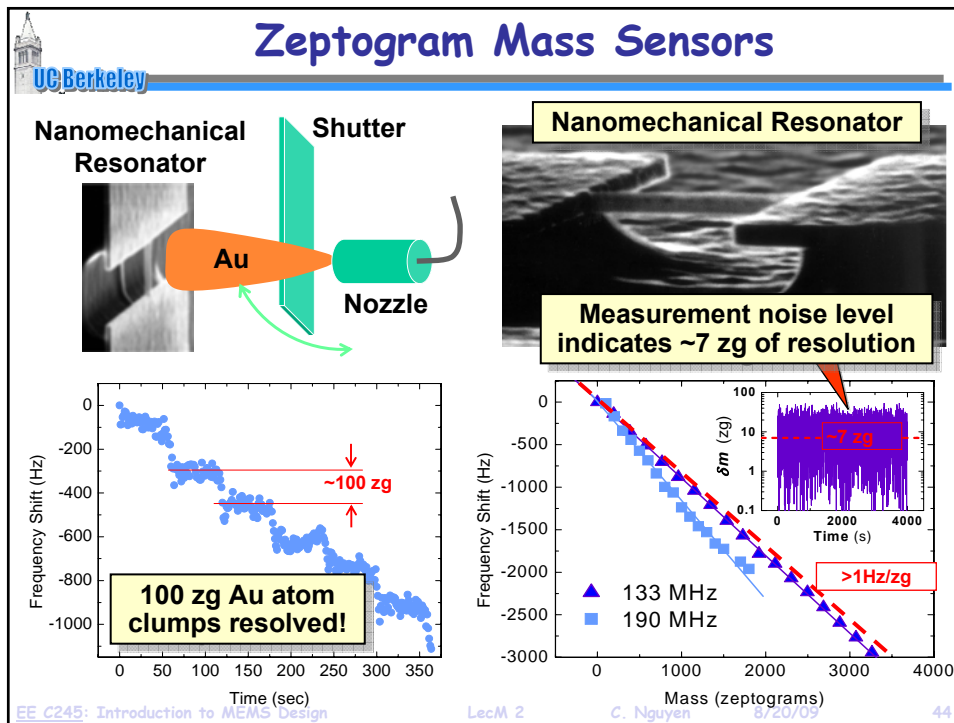
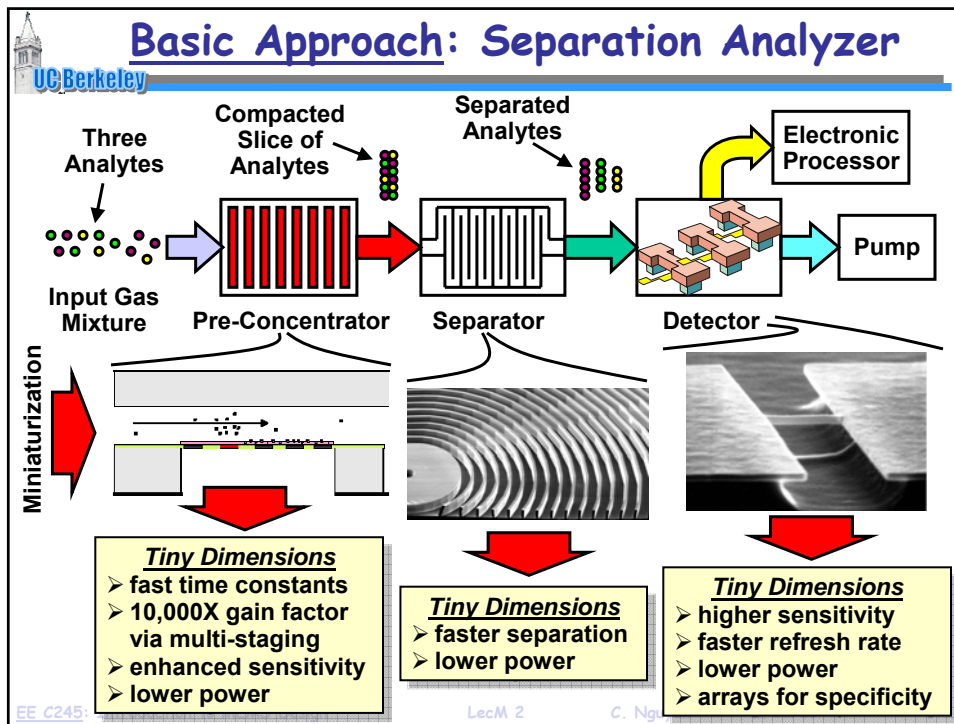
➔

Separation Distance ↓


- Result of Scaling:** shorter column length; faster analysis time

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Gas Analyzer Technology Progression



Agilent 6852A
 Vol: 60,000 cm³
 Power: 20 W
 Energy/Analysis: 18 kJ
 Analysis Time: 15 min.



LLNL
 Vol: 40,500 cm³
 Power: 11.5 W
 Energy/Analysis: 10 kJ
 Analysis Time: 15 min.



Sandia μChem Lab
 Vol: 1,050 cm³
 Power: 4.5 W
 Energy/Analysis: 540 J
 Analysis Time: 2 min.

Gas Chromatograph/Mass Spectrometer (GC/MS) is a "gold standard" in chemical gas detection with excellent immunity to false alarms

Problems: too big, too slow, power hungry

Solution: use MEMS technology to miniaturize the GC/MS, which in turn makes it faster and more energy efficient

MGA Objective
 Vol: 2 cm³
 Power: <200 mW
 Energy/Analysis: 1 J
 Analysis Time: 4 s

Advantages:

- > small enough for projectile delivery
- > 1 ppt det. limit
- > very fast
- > battery operable

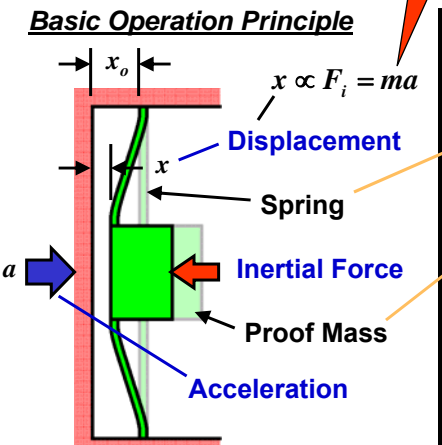
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Example: Micromechanical Accelerometer

The MEMS Advantage:

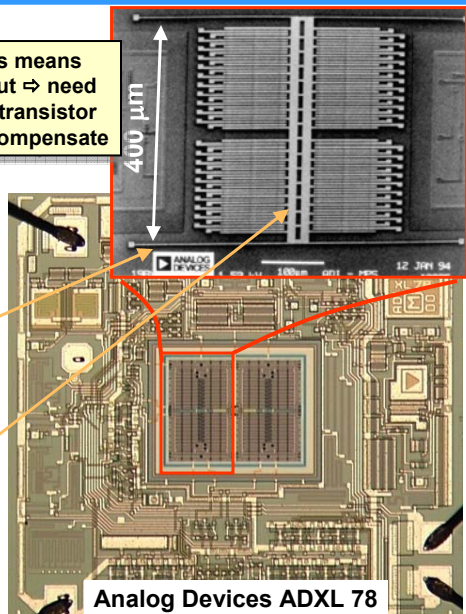
- >30X size reduction
- accelerometer mech
- allows integration w

Basic Operation Principle




$x \propto F_i = ma$

Tiny mass means small output ⇒ need integrated transistor circuits to compensate




Analog Devices ADXL 78

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 **Messages Going Forward ...**

- MEMS are micro-scale or smaller devices/systems that operate mainly via a mechanical or electromechanical means
- MEMS \Rightarrow NEMS offer the same scaling advantages that IC technology offers (e.g., speed, low power, complexity, cost), but they do so for domains beyond electronics:

Size \downarrow 

- resonant frequency \uparrow (faster speed)
- actuation force \downarrow (lower power)
- # mechanical elements \uparrow (higher complexity)
- integration level \uparrow (lower cost)

- Micro ... nano ... *it's all good*
- Just as important: MEMS or NEMS have brought together people from diverse disciplines \Rightarrow this is the key to growth!
- What's next? \Rightarrow Nano-nuclear fusion? Chip-scale atomic sensors?

... **limitless possibilities** ...

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